

Phospho-Histone H2A.X (Ser139) Recombinant antibody

Cat: B36222S

Company: HaoKebio

Uniprot ID: P16104

Applications: IHC:1:2000-1:8000

Organism: Rabbit

IHC-Polymer:1:8000-1:32000

Species reactivity: Human Mouse Rat

IHC-TSA:1:10000-1:40000

Molecular Weight Calculation: 15 kDa

IF:1:100-1:400

Observed Molecular Weight: 15 kDa

WB:1:5000-1:50000

FC:1:1000-1:2000

Background:

The histone variant H2AX is a major component of the DNA damage response (DDR), especially functioning in amplifying DNA damage signals. In response to DNA double-strand breaks (DSBs), H2AX is instantaneously phosphorylated at Ser 139 (a form called γ H2AX) by the kinases ATM and ATR. The phosphorylation of H2AX at Ser139, resulting in the formation of γ -H2AX puncta in the nuclei, is an early event in the cellular response to DNA damage. Therefore, phospho-Histone H2A.X (Ser139) is also known as γ H2AX. The phosphorylation site of H2AX, Ser139, has also been described as Ser140 in other literature, and they recognize the same amino acid site.

Synonyms:

H2A.X (Ser139), H2A.X P-S139, H2A.X Ser139, H2A.XS139, H2A.XS139Ph

Immunogen:

Recombinant protein

Isotype:

IgG

Subcellular location:

Nucleus

Purity:

Affinity purification

Form:

Liquid

Storage Buffer:

PBS with 0.02% sodium azide, 100 μ g/ml BSA and 50% glycerol.

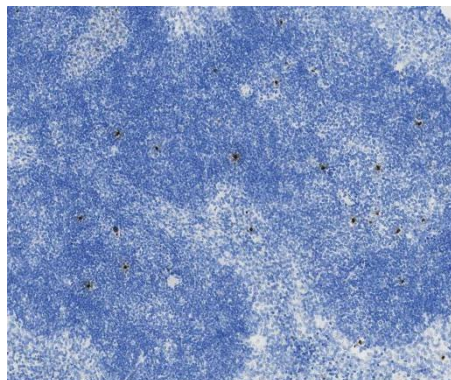
Storage:

Store at -20 °C for one year.

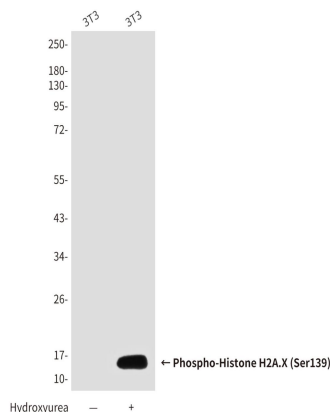
Experimental procedure:

Antigen retrieval: Citrate buffer (pH 9.0), Medium high heat for 8 minutes, stop for 7 minutes, medium high heat for 8 minutes. Incubate antibody, 4°C overnight. Secondary antibody: Poly-HRP Goat Anti-Rabbit & Mouse Universal Secondary Antibody, RT, 1h.

Images:



Sample: Mouse spleen, 4% PFA 12-24h



Dilution of 1:10000 incubated at room temperature for 1.5 hours.

Source of Reagents:

For research use only. Not for use in diagnostic procedures.

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(Ser139)(B36222S)由杭州浩克生物技术有限公
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